Bendable crystals in Bragg geometry

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- Overview of focusing
- Hooke's law + parameters
- ODE beamline description
- Data analysis
- Conclusion



• Image size \rightarrow two factors : source size and mirror defects









slope error effect on focus <u>....</u> • 1 m <u>...</u>..... **** 3x10⁸ σ = 2 μm RMS o gauss □ sinus 2x10⁸ e = 1 µrad RMS z (ope error (ured) a.u. 1x10⁸ -3 L -100 50 100 leng kijm m O Slope error : $\varepsilon = 1 \mu rad RMS$ -10 -5 5 10 0 Sinusoidale shape size (µm)







Sinusoidale defects in crystals

Si111 crystal at 7 keV (θ = 16.41°)

Sine defect : A = $1.8 \mu m$, D = 80 mm, L = 200 mm



DUMOND Diagrams

The DUMOND Diagram changes according to the position of the detector



• Local crystal curvature effect (Using Takagi-Taupin crystal theory)



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Depth penetration length effect





Focal size limitation for crystals



Х

Х

 C_2



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• Curvature





Ellipse representation







• Width side





Change of energy

Si111 ODE crystal, L = 300 mm, h = 1.6 mm p = 17.2 m, q = 1.2 m Triangular width optimized at 7 keV (θ = 16.41°)



E (keV)	θ (°)	C ₁ (N.m)	C ₂ (N.m)	
5	23.30	0.2018	0.2077	
6	19.24	0.1675	0.1739	
7 (opt)	16.41	0.1432	0.1495	
10	11.41	0.1000	0.1050	

The RMS slope error is acceptable for a large spectral domain

The residual slope error shape may structured the Dumond diagram





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ODE beamline : EDXAS

- X-ray magnetic Circular Dichroism
- Materials under extreme conditions
- Chemistry and time resolved measurements





Bent crystal





Zn edge measurement

 $E = 9659 \text{ eV}, \theta_0 = 11.81^\circ, \Delta E = 600 \text{ eV}$









 \rightarrow A = 100 nm, D = 80 mm, ε = 5.3 µrad RMS

 $\Delta x_{the} = 30 \ \mu m FWHM$ $\Delta x_{mes} = 45 \ \mu m \ FWHM \ (factor 1.5)$

 $\delta = 114 \ \mu m$





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• Shape of the surface





Zn edge simulations

🔶 E=	9659	eV,	$\theta_0 =$	11.81	1°, ∆E	= 600	eV
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Intensity modulation scheme

➡ Intensity modulation = f(source size, period defects, beam divergence)





- Olivier Mathon, ESRF
- François Polack, Gilles Cauchon and Rachid Belkhou, SOLEIL
- ODE beamline team and Metrology Laboratory team of SOLEIL



Ray tracing software SPOTX

- Based on the MonteCarlo method
- Dynamical absorption calculation
- Very fast and well suited for X-ray beamlines simulations

Surfaces defects

- 🛉 Function (sinusoidal, ..)
- Random
- Data file : profilometer, interferometer